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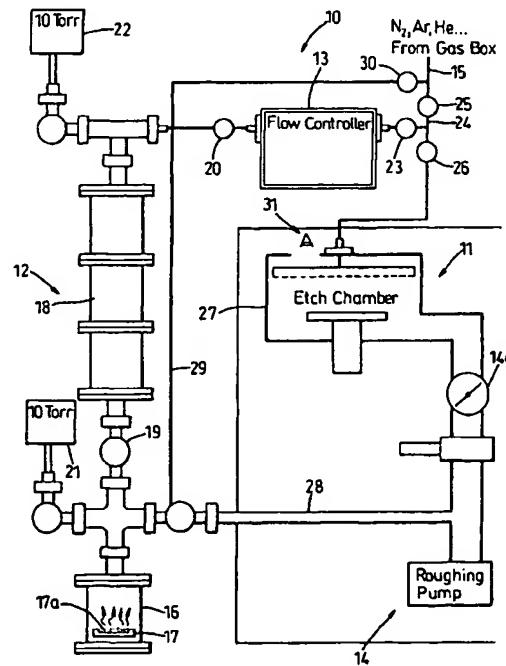
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(54) Method and apparatus for etching a workpiece

(57) An XeF₂ source 12 comprises a XeF₂ source chamber 16, which includes a tray or ampoule 17 for XeF₂ crystals 17a, a reservoir 18 via valve 19, a flow controller 13 fed by the reservoir 18 and a valve 20 be-

tween the reservoir 18 and the controller 13. Pressure sources 21 and 22 are provided respectively to maintain the reservoir 18 and the source chamber 16 at the sublimation pressure of XeF₂. The arrangement allows for a steady supply of XeF₂ to an etching chamber.



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EUROPEAN SEARCH REPORT

Application Number
EP 98 30 3196

DOCUMENTS CONSIDERED TO BE RELEVANT			CLASSIFICATION OF THE APPLICATION (Int.Cl.6)
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	
E	PATENT ABSTRACTS OF JAPAN vol. 1998, no. 13, 30 November 1998 (1998-11-30) & JP 10 209088 A (MITSUBISHI ELECTRIC CORP), 7 August 1998 (1998-08-07) * abstract *	1-3,6,8	H01J37/32
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			TECHNICAL FIELDS SEARCHED (Int.Cl.6)
			H01J
<p>The present search report has been drawn up for all claims</p>			
Place of search	Date of completion of the search	Examiner	
THE HAGUE	25 November 1999	Schaub, G	
CATEGORY OF CITED DOCUMENTS		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document	
X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document			

ANNEX TO THE EUROPEAN SEARCH REPORT
ON EUROPEAN PATENT APPLICATION NO.

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JP 61134019 A	21-06-1986	NONE	

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For more details about this annex : see Official Journal of the European Patent Office, No. 12/82

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